

AGRANA STARCH

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Body Lotion (O/W) with CORN PO4 PH"B"

"developed & formulated exclusively by CLR"

Ingredients	INCI-Name	%w/w	Supplier
Phase A1			
Water	Aqua	ad 100	
CORN PO4 PH "B"	Distarch Phosphate	2,0	AGRANA
Phase A2			
Glycerin	Glycerin	1,0	
Urea	Urea	0,8	
Phase B			
Brij 020	Oleth-20	2,5	Croda
Tegosoft TN	C12-15 Alkyl Benzoate	6,0	Evonik
Edenor L 2 SM GS	Stearic Acid, Palmitic Acid	2,0	Emery
Lanette O	Cetearyl Alcohol	1,5	BASF
Xiameter PMX- 200 Silicone Fluid	Dimethicone	3,0	Dow Coming
Arlacel 165	Glyceryl Stearate, PEG-100 Stearate	2,0	Croda
Cetiol SB 45	Butyrospermum Parkii (Shea Butter)	1,0	BASF
Copherol 1250	Tocopheryl Acetate	0,5	Cognis
Phase C			
Curasan™	Water, Decyl Glucoside, Panthenyl Ethyl Ether, Glyceryl Laurate, Tocopheryl Acetate, Phytantriol, Lactic Acid, Chitosan	3,0	CLR
Maricol CLR	Soluble Collagen	4,0	CLR



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Phase D

Euxyl K700*	Phenoxyethanol, Benzyl Alcohol, Potassium	0.8	Schülke
	Sorbate, Aqua, Tocopherol	5,0	

Phase E

NaOH (10%) Sodium Hydroxide	q.s.	
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^{*)} This formula has been manufactured and stability tested using a special preservative, but has not been subjected to microbiological challenge tests.

PROCEDURE

- 1. Pre-disperse A1 under stirring and add A2.
- 2. Heat up A and B to 80 °C separately.
- 3. Add B to A and homogenize for 5 minutes.
- 4. Cool down under stirring to 50 °C.
- 5. Adjust pH-value to 5,4-5,5 with E.
- 6. Add the parts of C at room temperature.
- 7. Add D under stirring.

pH-value: 5,4

The recommendations and formulations given are based on our knowledge and experience in the field of technical application. They are, to the best of our belief, correct, but are offered without obligation. Those who use our recommendations and formulations as well as those who process CLR Active Agents are themselves responsible for the adherence to prevailing statutory regulations and the observance of patent rights as well as other protective rights for other companies.